



H1 Genuine] diamond film deposition preparation process and application(Chinese Edition)

By DAI DA HUANG ;

paperback. Book Condition: New. Ship out in 2 business day, And Fast shipping, Free Tracking number will be provided after the shipment. Pub Date: 2001 Pages: 2001 Publisher: Metallurgical Industry Press title: preparation process and application of diamond thin film deposition Original: \$ 20 author: Dai Dahuang.; Press Zhouke Song: Metallurgical Industry Press Publication Date: June 2001 ISBN: 9787502427757 words: Page :2001 -01-01 Edition: Binding: Folio: Product ID: Wing Garden: 390.203. Metallurgical Industry Press Editor's book is available in the materials science and engineering researchers. the engineers and technicians reference. particularly those engaged in the diamond film technology workers who read the; also available materials professional high-grade students. graduate students engaged in the diamond film studies. EXECUTIVE SUMMARY This is a more comprehensive description of the preparation of diamond film deposition technology and application book. Book from the excellent performance and application prospects of the diamond film on the preparation of the deposited film; discusses the dynamics of growth of diamond thin film of non-equilibrium thermodynamics and diamond film; discussed more detailed large-area deposition of diamond The film's hot-wire apparatus and deposition rate today the highest plasma jet device some key technology and film-forming process; DLC film preparation process performance close...



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